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<th>On-chip antennas for 60-GHz radios in silicon technology (Published version)</th>
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active/standby power requirement in a single chip can result in the coexistence of both PD and FD devices in the same circuit by design, as indicated by (7).

Using (7) to estimate the immunity of floating-body effect for devices with various feature size is also crucial to SOI compact modeling. To circumvent the modeling challenge imposed by the trend of scaling of PD device geometries to maintain comparable performance, the modeling challenge imposed by the trend of scaling of PD device geometries to maintain comparable performance.

In conclusion, the geometry-dependent floating-body effect can be explained and predicted by the correlation between $\Delta V_{FB}$ and $V_T$. This brief points out the underlying mechanism responsible for the coexistence of PD and FD devices in a state-of-the-art SOI chip.

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REFERENCES


On-Chip Antennas for 60-GHz Radios in Silicon Technology

Y. P. Zhang, M. Sun, and L. H. Guo

Abstract—The recent advances in 60-GHz radios have called for the parallel development of compact and efficient millimeter-wave antennas. This brief addresses for the first time the design, fabrication, and characterization of on-chip inverted-F and quasi-Yagi antennas for 60-GHz radios. The design was made using the Zeland ICED software package. The fabrication was realized with the back-end-of-line process of silicon substrates of low resistivity $10 \Omega \cdot \text{cm}$. The characterization was conducted on wafer with Cascade Microtech coplanar probes and an HP8510XF network analyzer.

The results show that the inverted-F antenna achieved a minimum return loss of $32 \mathrm{~dB}$ and a gain of $-10 \mathrm{~dB}$ at 61 GHz; while the quasi-Yagi antenna achieved a minimum return loss of $67.5 \mathrm{~dB}$ and a gain of $-12.5 \mathrm{~dB}$ at 65 GHz. Good agreement has been observed between the measured and simulated results.

Index Terms—60-GHz radios, inverted-F antennas, on-chip antennas, quasi-Yagi antennas, wireless personal area network (WPAN).

I. INTRODUCTION

There is much interest today in exploiting the 60-GHz band for wireless personal area network (WPAN) applications because a large bandwidth of 7 GHz is available [1]. The large bandwidth and millimeter-wave frequency have indeed created many challenges in the design of radio front-ends. The 60-GHz radio front-end implemented as an assembly of microwave monolithic integrated circuits (MMICs) in gallium arsenide (GaAs) semiconductor technology has proven feasible but rather expensive [2]. The 60-GHz radio front-end based on MMICs in silicon germanium (SiGe) semiconductor technology has been attempted. For instance, Renolds et al. demonstrated 60-GHz radio front-end circuits including a low-noise amplifier (LNA), a direct down converter, a power amplifier, and a voltage-controlled oscillator (VCO) in SiGe technology [3]. Design toward realizing a low-cost fully integrated SiGe 60-GHz radio front-end has been carried out. As the high-frequency capabilities of complimentary metal oxide semiconductor (CMOS) technology improve through scaling, CMOS has become a viable technology for millimeter-wave operation. Doan et al. has explored CMOS for 60-GHz applications and designed an LNA using a standard $0.13 \mu m$ CMOS process [4]. Liu et al. demonstrated 64- and 100-GHz VCOs in 90-nm CMOS [5]. Liu et al. demonstrated a 63-GHz VCO in a standard $0.25\mu m$ CMOS [6]. In addition, CMOS technology that promises to integrate a complete 60-GHz system (radio front-end plus digital processor) on a single chip (SoC) further enhances its competitiveness.

An antenna plays a key role in a radio. It has independent properties that affect the radio as a whole. Current antennas for 60-GHz radios are mainly discrete designs on conventional dielectric substrates [7], [8]. A relatively new development for 60-GHz antenna designs is the application of multichip module (MCM) technologies, which embeds antennas into integrated circuit packages [9]. At 60 GHz, the antenna form factor is on the order of millimeters or less and opens up new
II. DESIGN OF ON-CHIP INVERTED-F AND QUASI-YAGI ANTENNAS

Antennas for 60-GHz applications should feature the following properties: 1) low fabrication cost and readily amenable to mass production; 2) light weight and small size; 3) high efficiency and broad bandwidth; and 4) integratable with other radio front-end circuitry [1]. Most antennas on silicon substrates of high resistivity are microstrip antennas, planar inverted-F antennas and Yagi–Uda antennas [10]–[12]. Considering the potential that the microstrip patch and the planar element may cause micro fracture to the silicon substrate, we chose linear inverted-F and quasi-Yagi antennas for our brief.

The linear inverted-F antenna consists of a horizontal line, a short-circuited vertical line, and a signal-driven vertical line. It is well known that the inverted-F antenna originated from the modification of the inverted-L antenna. The modification is very important because the input impedance of an inverted-F antenna can be arranged to have an appropriate value to match the source impedance, without using any additional circuit between the antenna and the source. One more important property of the inverted-F antenna is its performance with both vertical and horizontal polarizations, because the antenna has both the vertical and horizontal elements. Its performance with two-polarization would be very useful for WPAN applications. In a WPAN environment, the radio signal has random fluctuating distributions, compounding of the vertical polarization and the horizontal polarization can provide a diversity effect and improve the reception. Another advantage of the inverted-F antenna is its small vertical dimension, which enables it to be favorable for on-chip integration as it can be designed at one of chips’ edges. Taking these facts into account it can be said that the inverted-F antenna is an especially attractive antenna for WPAN applications.

The Yagi–Uda antenna has found wide applications in the HF–UHF band. For frequencies up to millimeter-wave range, microstrip-fed quasi-Yagi antennas have been built on conventional dielectric substrate ($\varepsilon_r = 9.8$) [14]. The Yagi–Uda is based on the principles of parasitic elements that are not directly fed by an energy source. These elements focus the radiation pattern using currents induced in them by radiation from the driven element. According to their length and spacing from the driven element, the parasitic elements become either directors or reflectors. Directors are shorter than the driven element and result in the radiation pattern being sharply focused in the direction of the directors. Reflectors are longer than the driven element and result in a radiation pattern directed away from them. The overall result is an endfire radiation pattern, which is an attractive property for point-to-point radio communications [12].

The inverted-F and quasi-Yagi antennas were designed using the electromagnetic simulator Zeland IE3D. This software package based on the methods of performs a full wave electromagnetic analysis of dispersion, discontinuities, surface waves, higher order modes, conductor loss, dielectric loss, and radiation loss.
Fig. 3. Radiation patterns of the inverted-F antenna (azimuth plane: $\theta = 85^\circ$. Elevation plane: $\psi = 0^\circ$).

copolarization radiation, for example, in the $0^\circ$ direction the cross-polarization radiation is $32$ dB weaker. In the elevation plane, the radiation patterns, both co- and cross-polarizations can only be obtained for the upper hemisphere because the electromagnetic model assumes infinite extension of the ground plane. The copolarization radiation pattern becomes asymmetric because of the shorted-circuit line element. The radiation gets stronger in the directions away from the shorted-circuit line element. The cross-polarization radiation is stronger as compared with that in the azimuth plane. The cross-polarization radiation is only about $9$ dB weaker than the copolarization radiation in the $0^\circ$ direction in the elevation plane.

B. Quasi-Yagi Antenna

Fig. 4 shows the layout, cross-sectional view, and top view photographs of the on-chip quasi-Yagi antenna. It consists of one driver, two directors, and a truncated ground plane that acts as reflector. The antenna is fed by a microstrip line. It should be mentioned that the GSG probes require the testing pads being squares of $80 \mu m \times 80 \mu m$ with a pitch of $100 \mu m$. As a result, the impedance between the signal pad and the ground plane with $2-\mu m$-thick silicon oxide separation is small. This small impedance of a few ohms avoids the short circuit and a part of the signal reach the antenna to radiate.

It is known that the quasi-Yagi antenna has significantly more gain and a better-controlled front-to-back ratio when it employs at least three elements. We chose four elements for our design [14]. As shown in Fig. 4(a), parameters considered to optimize the design are $L_1$, $L_2$, $L_3$, and $L_4$. Parameter $L_1$ is the distance between the driver and the first director, which equals the distance between the first director and the second director to simplify the design. Parameter $L_2$ is the distance between the driver and the ground plane, parameter $L_3$ is the length of the director, and parameter $L_4$ is the length of the driver. The optimized parameters are $L_1 = 146$, $L_2 = 270$, $L_3 = 382$, and $L_4 = 426 \mu m$. It is found that the return loss is insensitive to the variation of parameters $L_1$ and $L_3$. When $L_1$ is varied by $30$ from $116$ to $176 \mu m$, and $L_3$ by $30$ from $352$ to $412 \mu m$, respectively, the return loss remains unchanged.

It is also found that the return loss is sensitive to the variation of parameters $L_2$ and $L_4$ as shown in Fig. 5. They affect both impedance bandwidth and resonant frequency. The resonant frequency increases when the parameter $L_2$ increases from $190$ to $350$ by $80 \mu m$. The resonant frequency decreases when the parameter $L_4$ increases from $376$ to $476$ by $50 \mu m$. The final optimized parameters for the quasi-Yagi antenna yield the axial length of the quasi-Yagi antenna $1.3 \text{ mm}$ and a broad $-10$ dB bandwidth from $55$ to $65$ GHz.

The simulated radiation patterns of the quasi-Yagi antenna in the azimuth and elevation planes at $60$ GHz are shown in Fig. 6. Note that the quasi-Yagi antenna results in low cross-polarization radiation. They are $18.7$ dB lower in the azimuth plane and $29.7$ dB lower in the elevation plane as compared with copolarization radiation. The poor front-to-back ratio is due to the lossy substrate configuration.

III. FABRICATION OF ON-CHIP INVERTED-F AND QUASI-YAGI ANTENNAS

The post BOEL process is illustrated in Fig. 7. Note that a standard low resistivity silicon wafer of diameter $8$ in and a thickness of $750 \mu m$ is used. First, a $6-\mu m$-thick SiO$_2$ layer is grown on the
Fig. 6. Radiation patterns of the quasi-Yagi antenna (azimuth plane: $\theta = 8^\circ$; elevation plane: $\varphi = 0^\circ$).

Fig. 7. BEOL process.

The inverted-F antenna was fabricated with the simplified post BEOL process. This can be seen from Fig. 1(b) where no aluminum layer is deposited and no deep via is formed. The inverted-F antenna is separated from the silicon substrate by a 20-$\mu$m-thick SiO$_2$ layer. The quasi-Yagi antenna was fabricated with the modified post BEOL process. As seen from Fig. 4(b), the antenna is formed by two 2-$\mu$m aluminum layers separated by a 2-$\mu$m SiO$_2$ layer. The driver, two directors, and its feeding structure are etched on the top aluminum layer, while the truncated ground plane used as the reflector is etched on the bottom aluminum layer. The ground pads are connected to the truncated ground plane by vias to eliminate the capacitance effect between the two aluminum layers. The whole antenna structure is separated from the silicon substrate by a 20-$\mu$m-thick SiO$_2$ layer. It is obvious that the antennas can be built on CMOS IC chips using the post BEOL process if they are proved to be successfully fabricated with the simplified post BEOL process discussed here.

IV. CHARACTERIZATION OF ON-CHIP INVERTED-F AND QUASI-YAGI ANTENNAS

The measurements were performed on-wafer with Cascade Microtech coplanar probes and an HP8510XF network analyzer. The $S$-parameters were measured for both antennas up to 110 GHz. Fig. 8(a) shows the measured and simulated return loss of the inverted-F antenna. It is evident from the figure that the measured result agrees well with the simulated one. It is more important to note from the measurement result that a sharp dip exists at 61 GHz, which indicates excellent antenna quality and good matching to the 50-Ω source. Using a threshold of $-10$ dB, the measured bandwidth for the inverted-F antenna covers from 55 to 67.5 GHz. Fig. 8(b) shows the measured and simulated return loss of the quasi-Yagi antenna. Note that a resonance null occurs at 65 GHz. Using a threshold of $-6$ dB,
the measured bandwidth covers from 61 to 70 GHz. The measured resonant frequency agrees with the simulated one. However, the matching is not good to achieve the lower return loss at the resonant frequency. It might be the reason of fabrication tolerance that makes the fabricated antenna not as fine as the designed. Fig. 8(b) also shows the tolerance influence of the thickness $t$ of the silicon oxide layer between the top antenna structure and the truncated ground plane on the return loss. This can give one important possible reason why the measured return loss is so low at the resonant frequency.

The gains of both inverted-F and quasi-Yagi antennas were measured with the technique presented in [15]. The technique requires two identical antennas placed face-to-face and separated by a distance $d$. The distance $d$ measures the separation between the reference planes used for far-field measurements. One antenna functions as a transmit antenna, the other as a receive antenna. From transmission measurements the antenna gain can be estimated by

$$G^2 = |S_{21}|^2 \left( \frac{4\pi d}{\lambda} \right)^2.$$ (2)

The technique does not permit one to determine the radiation pattern. However, the goal of this brief was to validate the design method and to optimize the process in order to integrate a complete 60-GHz radio front-end. The antenna gain is extracted from the measurements with $d = 20$ mm. In our measurement a gain of $-19$ dBi is obtained at 61 GHz for the inverted-F antenna; while a gain of $-12.5$ dBi at 65 GHz for the quasi-Yagi antenna. The simulated radiation efficiency is 3.5% for the inverted-F antenna and 5.6% for the quasi-Yagi antenna. If they were implemented in conventional CMOS, the simulated radiation efficiency would only be 1.7% for the inverted-F antenna and 2% for the quasi-Yagi antenna.

**V. CONCLUSION**

This brief discussed the design, fabrication, and characterization of the on-chip inverted-F and quasi-Yagi antennas for 60-GHz radios for the first time. The design was based on intensive electromagnetic simulations using the Zeland IE3D software package. The antennas were tested on-wafer for return loss and gain. The measurement results show that the inverted-F antenna achieved a minimum return loss of 32 dB and a gain of $-19$ dBi at 61 GHz, while the quasi-Yagi antenna return loss of 6.75 dB and a gain of $-12.5$ dBi at 65 GHz. Good agreement has been observed between the measured and simulated results for the inverted-F antenna. The discrepancy between the measured and simulated results for the quasi-Yagi antenna was due to the process inaccuracy. The performance of the on-chip inverted-F and quasi-Yagi antennas can be further enhanced with the packaging techniques. It is therefore anticipated that the results and design details on the on-chip antennas presented here are useful and inspiring for engineers interested in 60-GHz radio front-end designs.

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